## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Hiroyuki KANBARA et al.

Serial No.: Currently unknown

Filing or 371(c) Date: Concurrently herewith

Title: METHOD FOR FORMING THICK

FILM PATTERN, METHOD FOR MANUFACTURING ELECTRONIC

COMPONENT, AND

PHOTOLITHOGRAPHY PHOTOSENSITIVE

**PASTE** 

International Application No.: PCT/JP2004/015621

International Filing Date: October 21, 2004

## **EXPRESS REQUEST TO BEGIN NATIONAL EXAMINATION PROCEDURES**

Mail Stop PCT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

This is an express request to begin national examination procedures under 35 U.S.C. § 371(f). As required by 35 U.S.C. § 371(c), this submission includes a copy of the International Application as filed, unless a copy of the International Application has already been communicated by the International Bureau; an English language translation of the International Application as filed; and the national fee.

Respectfully submitted,

Dated: May 24, 2006

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